

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

MARK B. FUSELIER  
DERICK J. WRISTERS  
ANDY C. WEI

Confirmation No.: 9406

Group Art Unit: 2811

Serial No.: 10/821,230

Examiner: Ori Nadav

Filed: April 8, 2004

Att'y Docket: 2000.092182/TT5077D

For: SEMICONDUCTOR DEVICE FORMED  
OVER A MULTIPLE THICKNESS  
BURIED OXIDE LAYER, AND  
METHODS OF MAKING SAME

Customer No.: 23720

**CORRECTED RESPONSE TO OFFICE ACTION DATED NOVEMBER 16, 2006**Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This paper is submitted in response to the Office Action dated November 16, 2006, for which the three-month date for response was February 16, 2007. A request for a one-month extension of time to respond is included herewith. This one-month extension will bring the due date to March 16, 2007, which is within the six-month statutory period. The Director is authorized to deduct the fee for the one month extension (\$120), and any other fees under 37 C.F.R. §§ 1.16 to 1.21 required for any reason relating to this document, from Williams, Morgan & Amerson Deposit Account No. 50-0786/2000.092182.

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.